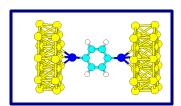
Huckel I-V 3.0: A Self-consistent Model for Molecular Transport with Improved Electrostatics

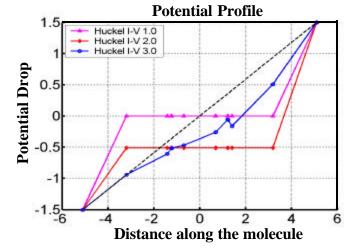
Ferdows Zahid
School of Electrical and
Computer Engineering
Purdue University

IWCE-10, Purdue University, October 24, 2004 M. Paulsson E. Polizzi A. W. Ghosh L. Siddiqui S. Datta

I. Introduction





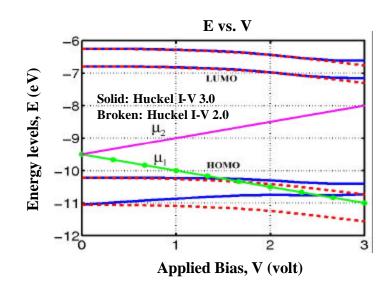


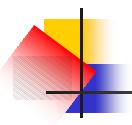


$$V_{scf}(?N) = U_0(N - N_{eq}) + 0.5V_{appl}$$



$$V_{scf}(??) = V_{Laplace} + V_{Poisson}(??) + V_{image}(??)$$





I. Introduction

Complete description of the self-consistent potential

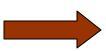


Spatial features retained

Both charging and screening effects included

Image corrections included

Three terminal calculations with proper electrostatics

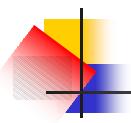


Degrees of freedom: number of gates, oxide thickness, oxide dielectric constant

Computationally inexpensive



Useful to do calculations on large molecular systems



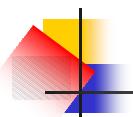
I. Introduction

Previous Huckel I-V models are on the Nanohub for public use

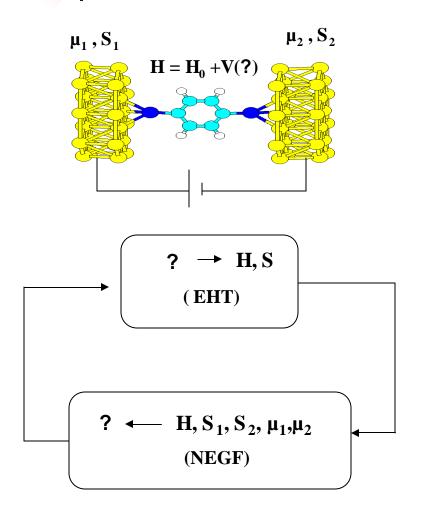
Huckel I-V 3.0 will be on the hub soon



www.nanohub.org



II. Description of the Model



Hamiltonian (H) and Overlap (S) matrices from EHT

Self-consistent potential V(?) using any suitable scheme

Self-energies $(S_{1,2})$ from the surface Green's function of the contacts

Density matrix (?) using NEGF



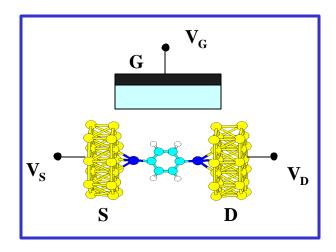
II. Description of the Model

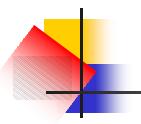
Self-consistent Potential

$$V_{scf}(\mathbf{r}) \rightarrow V_{scf}(\Delta \mathbf{r}) = V_{Poisson}(\Delta \mathbf{r}) + V_{image}(\Delta \mathbf{r}) + V_{Laplace}$$

From CNDO using the Hartree term

Solving 3D Laplace in real space using FEM





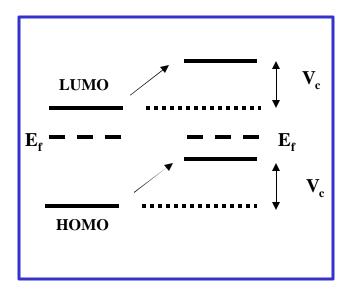
II. Description of the Model

Fitting parameter

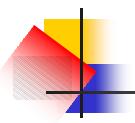
Only one fitting parameter (V_c)

V_c is a constant potential added to the molecular Hamiltonian

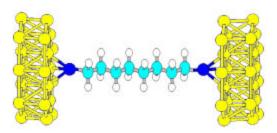
Fermi level of the device is kept fixed at the contact Fermi energy (-9.5 eV)

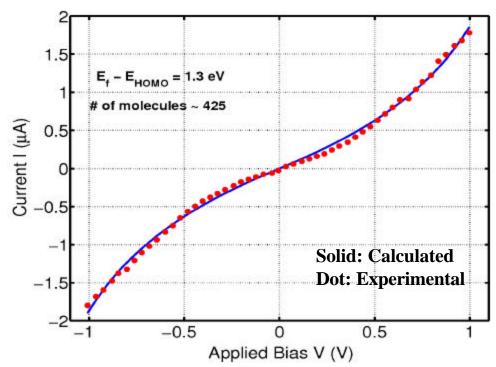


Effect of V_c



III. Results: I-V for Octane Dithiols





Two fitting parameters: V_c (i.e. E_f - E_{HOMO}) and effective number of molecules

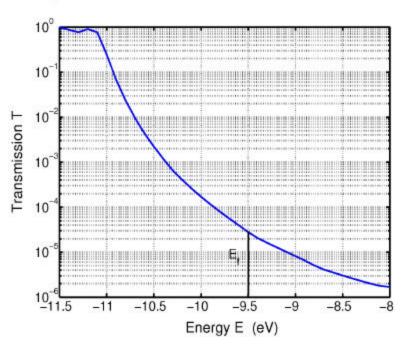
Strong coupling on both sides S-Au bond length = $2.53 A^{\circ}$

Nanopore data:

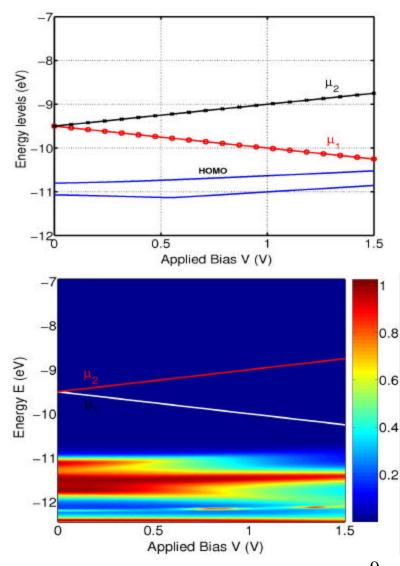
Reed, Nanoletters, v. 4, p. 643 (2004)



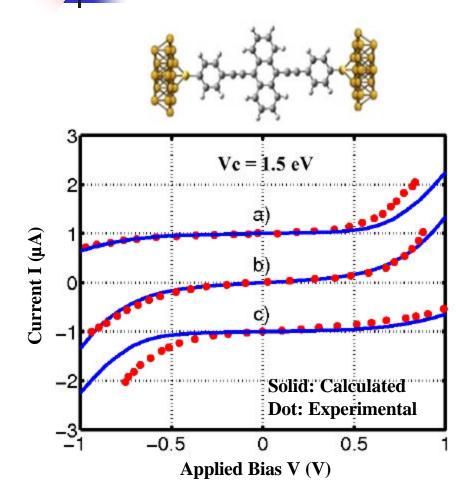
III. Results: I-V for Octane Dithiols



Conduction is in tunneling regime low transmission, low current



III. Results: Asymmetric I-V



- a) Left contact is weakly coupled
- b) Symmetric coupling
- c) Right contact is weakly coupled

Good quantitative match for both current value and shape

Asymmetry in the I-V is due to asymmetry in charging

Weak coupling is simulated by stretching S-Au bond length from 2.53 A° to 3.18 A°

Current is going through HOMO level and $E_f - E_{HOMO}$ is set to be 0.33 eV

Break Junction data:

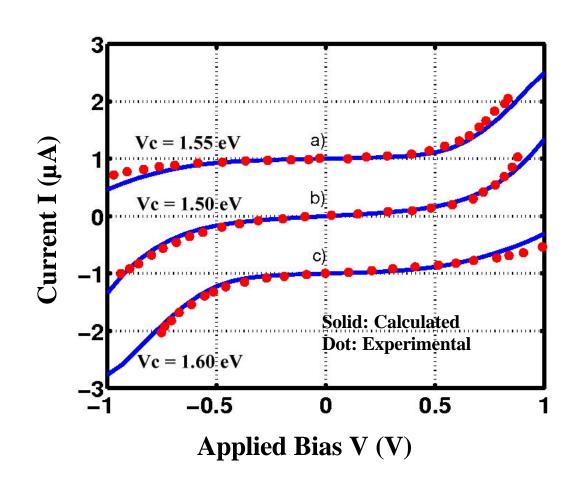
Weber, PRL v. 88, 176804 (2002)

Our results:

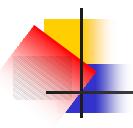
PRB v. 70, 2004 (in production)



III. Results: Asymmetric I-V



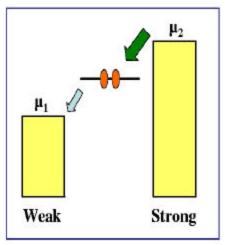
A better match is obtained with different V_c values for each curve



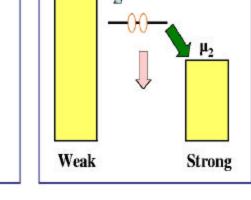
III. Results: Asymmetric I-V

Origin of Asymmetry

 μ_1



(a) V > 0



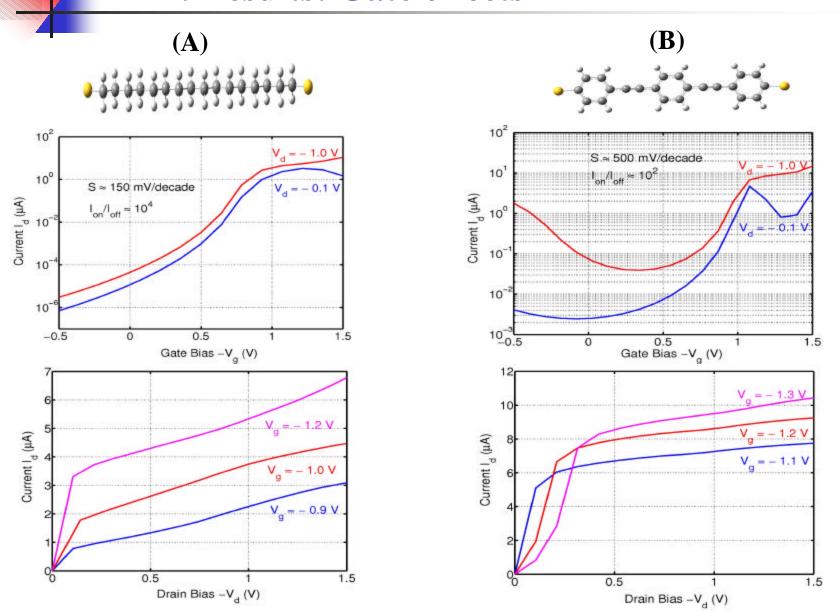
(b) V < 0

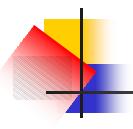
Asymmetric coupling gives rise to asymmetry in Charging

The molecule gets positively charged in the negative bias direction and that shifts the energy level down

In the positive bias direction the energy level remains filled and there is no charging

III. Results: Gate effects



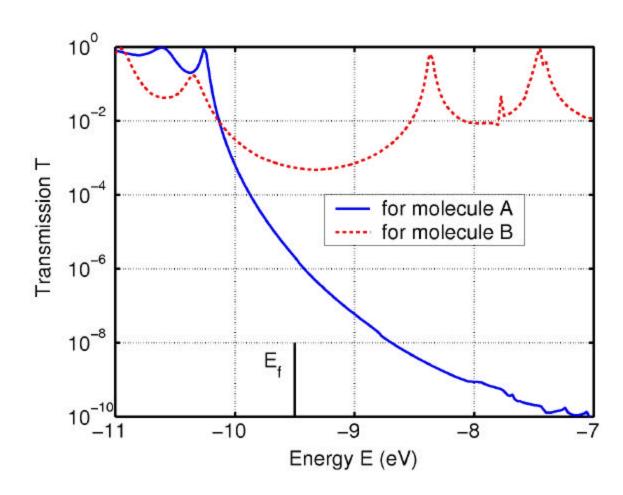


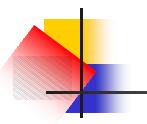
III. Results: Gate effects

Current is proportional to Transmission

Switching behavior is related to transmission

 $I_{on}/I_{off} \sim T(E_{HOMO})/T(E_f)$





IV. Summary

Huckel I-V 3.0: A new transport model with better and improved electrostatics

Main strengths of the model: full description of the potential profile inclusion of gate electrodes computationally inexpensive

Our calculations showed good agreement with few experimental results